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## Standard Terminology Relating to Polishes and Related Materials<sup>1</sup>

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This standard has been approved for use by agencies of the Department of Defense.

## **GENERAL**

buffable—the ability to improve gloss or general appearance, or both, of a polish film by a mechanical action.

**build-up**—<u>the</u> condition resulting from <u>a</u> lack of self-sensitivity in <u>a an existing</u> polish, whereby new film deposits over old, with little or no self-cleaning action.

**burnishing**—the enhancement of the existing polish appearance is accomplished by dry mechanical abrasion using a suitable machine and accessories.

cleaning—removal of marks, dust, and other extraneous materials from the surface.

coagulum—an agglomerate of particles.

creaming—the separation of a layer of the dispersed phase of an emulsion polish to the surface of the liquid continuous phase.

depth of gloss—the optical phenomenon of relative depth perceived when viewing reflective surfaces.

**detergent resistance**—the degree to which a polish film exhibits no apparent deterioration when spotted or cleaned with a solution of a nonabrasive, nonammoniacal detergent.

distinctness of image—degree of clarity exhibited by images reflected from a surface.

**drag**—physical resistance to spreading of a polish.

dry bright polish—a polish that dries to a gloss without buffing.

ease of use—cumulative effect of drag encountered in application or removal, or both, and the amount of time required to achieve the desired finish.

film clarity—characteristic of a deposited film which permits an unobstructed view of the substrate.

gloss retention—maintenance of gloss of a film under normal use conditions.

haze—film whose clarity is impaired with varying degrees of opacity.

leveling—the property of a freshly spread polish to dry to a uniform and streak-free appearance.

mar—mutilation of polish film reparable only by recoating.

**nonvolatiles**—materials remaining after the loss of volatile components.

polish—a temporary coating that enhances the appearance and may protect the substrate to which it is applied.

recoatability—the application characteristics of a polish and the appearance of the film after successive coatings to a surface.

soil—solid foreign matter embedded in or adhered on the surface.

**speed relating to rotary disc floor machines**—low speed: up to 800 r/min, high speed: more then 800 but less than 1500 r/min, and ultra high speed: 1500 r/min or more.

<sup>&</sup>lt;sup>1</sup> This terminology is under the jurisdiction of ASTM Committee D21 on Polishes and is the direct responsibility of Subcommittee D21.91 on Terminology and Editorial Review

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